

Examiner-Initiated Interview Summary	Application No.	Applicant(s)	
	10/662,962	NELSON, SHAWN	
	Examiner	Art Unit	
	Louis K. Huynh	3721	

All Participants:
Status of Application: RCE

 (1) Louis K. Huynh.

(3) _____.

 (2) Mr. David Dellebach (Reg. No. 39,166).

(4) _____.

Date of Interview: ____

Time: ____

Type of Interview:

- ☒ Telephonic
☐ Video Conference
☐ Personal (Copy given to: ☐ Applicant ☐ Applicant's representative)

Exhibit Shown or Demonstrated: ☐ Yes ☒ No

If Yes, provide a brief description:

Part I.

Rejection(s) discussed:

Claims discussed:

12 and 17.

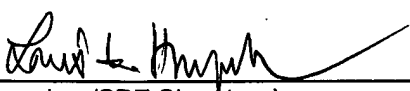
Prior art documents discussed:

Part II.
SUBSTANCE OF INTERVIEW DESCRIBING THE GENERAL NATURE OF WHAT WAS DISCUSSED:

See Continuation Sheet

Part III.

- ☒ It is not necessary for applicant to provide a separate record of the substance of the interview, since the interview directly resulted in the allowance of the application. The examiner will provide a written summary of the substance of the interview in the Notice of Allowability.
☐ It is not necessary for applicant to provide a separate record of the substance of the interview, since the interview did not result in resolution of all issues. A brief summary by the examiner appears in Part II above.


 (Examiner/SPE Signature)

(Applicant/Applicant's Representative Signature – if appropriate)

Continuation of Substance of Interview including description of the general nature of what was discussed:

The examiner proposed, and agreed to by applicant's attorney, to amend claims 12 and 17 in order to clearly define the claimed invention over the prior art of record and to place the application in condition for allowance.

The attorney, Mr. David Dellenbach, as a part of the duty to disclose information, has mentioned a similar rejection of the article claim groups in the parent application Ser. No. 10/074,597 using the same prior art: US Pat. No. 3,968,620 and US Pat. No. 5,476,184. However, the parent application and the present divisional application each has its own merits and each is examined on such merits. The patentability of one application does not depend on the patentability of the other since they are drawn to different and independent inventions.